

Beam tests of silicon pixel 3D-sensors developed at SINTEF

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ABSTRACT: For the purpose of withstanding very high radiation doses, silicon pixel sensors with a '3D' electrode geometry are being developed. Detectors of this kind are highly interesting for harsh radiation environments such as expected in the High Luminosity LHC, but also for space physics and medical applications. In this paper, prototype sensors developed at SINTEF are presented and results from tests in a pion beam at CERN are given. These tests show that these 3D sensors perform as expected with full efficiency at bias voltages between 5 and 15V.

KEYWORDS: Particle tracking detectors, 3D silicon pixel sensors, HL-LHC upgrade

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1 Introduction

The radiation hardness and rate requirements for tracking and vertex detectors to be operated in the High luminosity LHC are extremely severe, and a significant R& D effort is required before a viable system can be realized. The favored technology for the inner tracking elements are silicon pixel detectors. These possess many of the wanted properties and are now routinely used in virtually all experiments within high energy physics. However, significant development must be invested into improving the radiation hardness of the systems. The most exposed areas, close to the colliding beams, must be designed to withstand a fluence of $1.4 \times 10^{16} \text{cm}^{-2}$ 1 MeV n_{eq} (neutron equivalents). It is unlikely that conventional pixel sensors with planar p-n junctions and standard thickness can tolerate such large fluences. Therefore, research on sensors with alternative designs are being pursued. One research path is to drastically modify the diode structures. Instead of p-n junctions parallel to the sensor plane, a proposition where holes (perpendicular to the sensor plane) are etched into the silicon bulk and filled with alternate rows of p⁺ and n⁺ type electrodes [1] has been successfully prototyped [2], and also fabricated at SINTEF MiNaLab¹ [3]. The advantage of such structures is that full depletion can be achieved at very low bias due to the short distance between the electrodes. The carrier drift distances are also correspondingly reduced, resulting in reduced signal loss due to charge trapping, an effect that increase in severity as the radiation dose increases.

Very similar designs have also been realised in double sided processes, [4, 5] and are already successfully operated in the ATLAS IBL, as well as in the ATLAS AFP [6]. The purpose of this note is to report on developments and tests of prototypes that have been designed and produced in a single side, active edge process at SINTEF.

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2 Sensor and module design

The sensors tested here are $230\text{ }\mu\text{m}$ thick and are produced in a single sided process. The pixel size is $\Delta x \times \Delta y = 250 \times 50\mu\text{m}^2$ and is adapted to be read out by the ATLAS Front End readout chip I4 (FEI4) [7]. The etched vertical electrodes have a diameter of $14\text{ }\mu\text{m}$ nominally and are placed $125\text{ }\mu\text{m}$ apart in rows. The distance along y between two rows is $25\text{ }\mu\text{m}$, with a staggered position of electrodes in different rows, resulting in a spacing between electrodes of about $67\text{ }\mu\text{m}$.

The sensors consists of 80 columns and 336 rows, corresponding to an active area of nominally $20 \times 16.8\text{mm}^2$ for $250 \times 50\mu\text{m}^2$ pixels. A trench was made around the nominal sensor area, $16\text{ }\mu\text{m}$ wide, and centered $72.5\text{ }\mu\text{m}$ beyond the nominal edge of the outermost pixels, enlarging the sensitive area of the edge pixels in both directions (see sect. 4 for an evaluation of the extended sensitive area.) To be added to this are physical edges. The sensors have been cut using conventional wafer dicing, adding a dead margin of about $100\text{ }\mu\text{m}$. The overall physical size of the diced sensor is 20.32 by 17.65 mm^2 . The sensors were bump-bonded to the FEI4 readout chips. This procedure turned out to have some difficulties, and only very few assemblies remained suitable for testing in a test beam. Of the three assemblies put in the testbeam, one suffered from extremely high leakage currents. All three assemblies had dead (or extremely low efficiency) regions due to unsuccessful bump-bonding. However, it was easy to identify these regions, and exclude them from the analysis described below, where the purpose is to test the properties of the sensors, rather than the full module assembly.

2.1 Leakage current

The leakage currents of the modules were measured prior to mounting in the test beam, and monitored during the tests. Fig 1 shows the current characteristics of two sensor modules tested. Soft breakdown was observed to be around 12V and 20V . The low values for the breakdown voltages has been understood as pinholes created in metal masks during the DRIE process, as explained in ref. [8]. ² The third module had a problem with some large ohmic currents, which is thought to be external to the sensor itself. The module was nevertheless included for studies in the test beam.

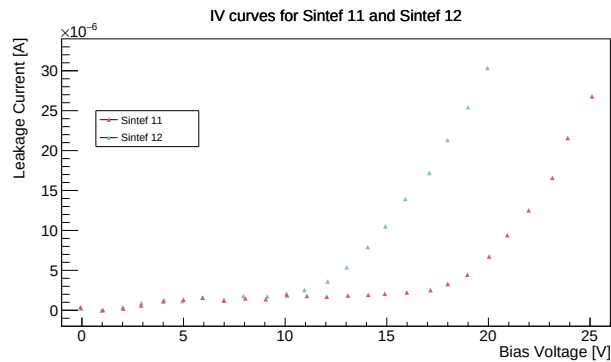


Figure 1. IV-characteristics of two of the sensors that were mounted in the test beam.

²Preliminary wafer tests of the subsequent production show that the a solution is found to this problem

3 Test beam setup and analysis

The modules were mounted in a beam line consisting of 120 GeV pions at the CERN H6 testbeam area during two testbeam periods in 2015 and 2016. The high resolution EUDET Pixel Telescope [9] was used to reconstruct the pion tracks through the setup. The telescope consists of 6 pixel planes, three placed 12 cm apart upstream of the devices under test (the DUTs) while the remaining three were placed downstream of the DUTs, also 12 cm apart. The core of the telescope is the Mimosa26 pixel sensor [10] with a pitch of $18.5 \mu\text{m}$. Each plane consisted of 576×1152 pixels covering an active area of $10.6 \times 21.2 \text{ mm}^2$. Triggering was achieved by the use of upstream and downstream sets of two $1 \times 2 \text{ cm}^2$ scintillators. During the second beam period, only five of the six planes were useable in the reconstruction.

For sufficiently high particle rate, the serial readout of the Mimosa26 sensors could result in ambiguities in the hits associated to a particular event. In many runs it was found that a given trigger contained hits from previous triggers, resulting in several high quality tracks being reconstructed per event. This problem was solved by requiring that at least one of the FEI4 modules mounted in the setup could serve as an additional reference. It was required that a signal in the reference module should be associated to an EUDET track before being passed on for analysis of the DUTs. This resulted in a very clean selection of good events for analysis.

For the runs studied below, the pointing resolution on the different DUTs was determined to vary from about $4 \mu\text{m}$ to about $8 \mu\text{m}$, depending on the position of the DUT in the setup, and on the number of active tracker planes.

4 Analysis and results

Before data collection in the beam, tuning of the FEI4 modules was necessary. The signal height in the FEI4 chip is recorded as a Time over Threshold (ToT) that is digitized in a 4-bit ADC. The modules were tuned to give an ADC signal of $\text{ToT} = 9$ as response to a charge release of 20000 electrons. Data were collected at thresholds of 2000, 2500, 3000 and 4000 electrons, and at biases of 5, 7.5, 10 and 15 Volts. When not stated otherwise, the results in the following are for data taken at 10V bias, and a threshold of 3000 electrons. No significant variation of efficiencies were found for the different biases and threshold although dependencies at the level of 1-2 permille could not be ruled out. [11]

4.1 Cluster and signal sizes

The first step in the data analysis was to assemble all individual hits in a sensor to *clusters*, consisting of a collection of neighbouring pixels with charge deposition. The clustering algorithm added neighboring hits to the cluster until all neighbours with charge deposition were found. Fig 2 shows the distribution of cluster sizes (the number of individual hits included in a cluster), and the distribution of summed ToTs in the clusters. These quantities showed very weak dependence on the settings of the runs (thresholds and biases).

4.2 Efficiency

Good tracks, i.e. tracks with low χ^2 and with a hit in the reference FEI4 module associated to it, were used for the efficiency analysis. If a signal from a particular DUT could be associated to the

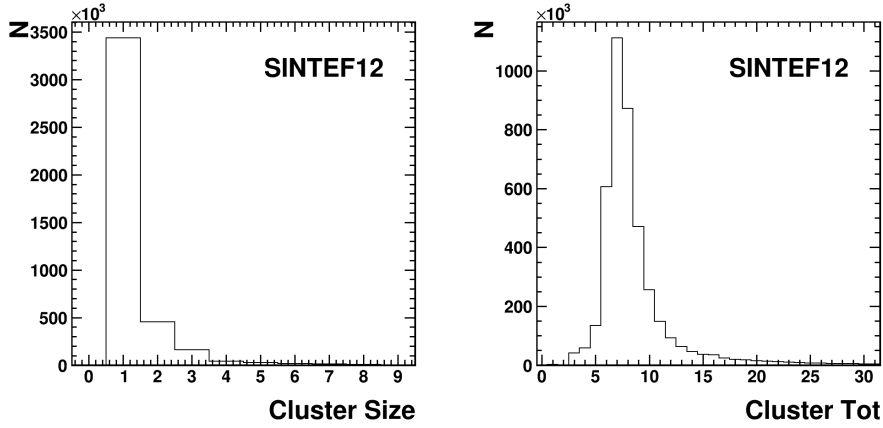


Figure 2. Distribution of cluster sizes (left), and summed times over threshold (right). These data are for the module SINTEF12 with a bias of 7.5V and a threshold of 2000 electrons.

track, it was assumed that the signal was caused by the particle producing the track. The efficiency was computed as function of the predicted track impact position in the DUT, and is given as the number of times the track could be associated to a pixel divided by the total number of tracks in that impact position. The dependence of the efficiency on the window size for track-hit association was studied, and it was found to reach a slowly rising plateau some 50-100 microns beyond the nominal edges [11]. The sensor was defined to have seen the passing particle if a hit pixel was found inside a window of total size $0.25 \times 0.45 \text{ mm}^2$ around the predicted impact position given by the reconstructed track.

Fig. 3 shows the distribution of efficiencies measured individually for each pixel, when the predicted track position is used to give the identity of the pixel. A number of pixels in each sensor had very low efficiency due to unsuccessful bump bonding, and do not show up in the figure because it falls below the lower limit of 0.5.

When computing average pixel efficiencies in figures and plots below, only pixels showing up in fig. 3 are used (i.e. with efficiencies larger than 0.5). This effectively excluded those areas on the chip that are dead, and clearly included all pixels that are successfully bonded and read out. Subsequent efficiency estimates of active pixels are not biased by this requirement.

The reason for the loss in efficiency in 3D sensors is the presence of the vertical electrodes in the sensors, in the following denoted by the term 'holes'. In order to demonstrate that this is the case, fig. 4 shows the efficiency profile as function of track impact position, averaged over all pixels. It is clearly seen that the loss is indeed at the location of the electrodes.

In order to characterize this further, the efficiency was computed as function of distance from the nearest nominal electrode center. Fig. 5 shows plots of this efficiency profile. The efficiency profile was modeled as a step function smeared with a gaussian, with four parameters; the efficiency in the holes, the efficiency outside the holes, the radius of the holes and the sigma of the gaussian. The fits are reasonable, and the values obtained for the smearing sigma are consistent with the expected tracking resolution (as obtained from studies of single pixel efficiency profiles). The transition region between the holes and the silicon bulk is much smaller than the impact

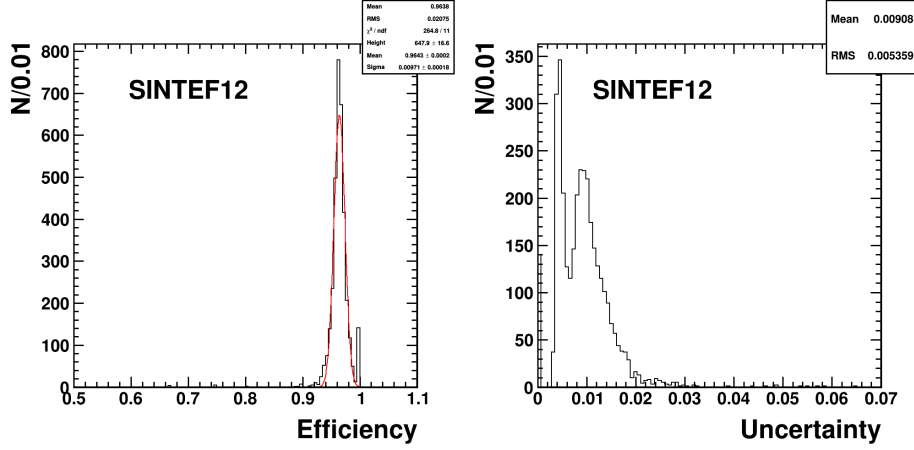


Figure 3. Distribution of individual pixel efficiencies (left), and distribution of statistical uncertainty of the individual efficiency estimates (right). There is variation in the uncertainties due to large differences in the number of tracks passing through the different pixels. The mean value of the estimated uncertainties is close to with the fitted spread in efficiencies observed. This is consistent with expectation when all pixels in the plot have the same true efficiency.

resolution, and compatible with a step function. The effective hole radius is found to be close to the nominal 7 microns. The values of the fitted parameters are summarized in table 1. However, reliable efficiency estimates in the holes cannot be claimed since the obtained hole efficiencies are not compatible with each other. Both the step function efficiency modelling as well as gaussian modelling of the pointing resolution are oversimplifications.

Table 1. Fitted parameters obtained for the fits depicted in fig. 5. The quoted uncertainties are statistical only. Note: The fitting procedure for the plateau efficiency returns statistical uncertainties in the fourth digit after the decimal point.

Sensor	Resolution (μm)	Hole radius (μm)	Hole efficiency	Plateau efficiency
SINTEF10	5.8 ± 0.2	6.2 ± 0.5	0.35 ± 0.04	0.999
SINTEF11	6.2 ± 0.3	5.2 ± 0.7	0.32 ± 0.06	0.998
SINTEF12	3.5 ± 0.1	6.4 ± 0.2	0.20 ± 0.03	0.999

The fitted parameters are consistent with expectation: The spacial track impact resolutions obtained are consistent with what is obtained by other means (studying the smearing of efficiency profiles at pixel edges [11]). The hole radii are also consistent with expectation. Outside the holes, it is seen that the efficiency is extremely high and consistent with 100% for two of the sensors.

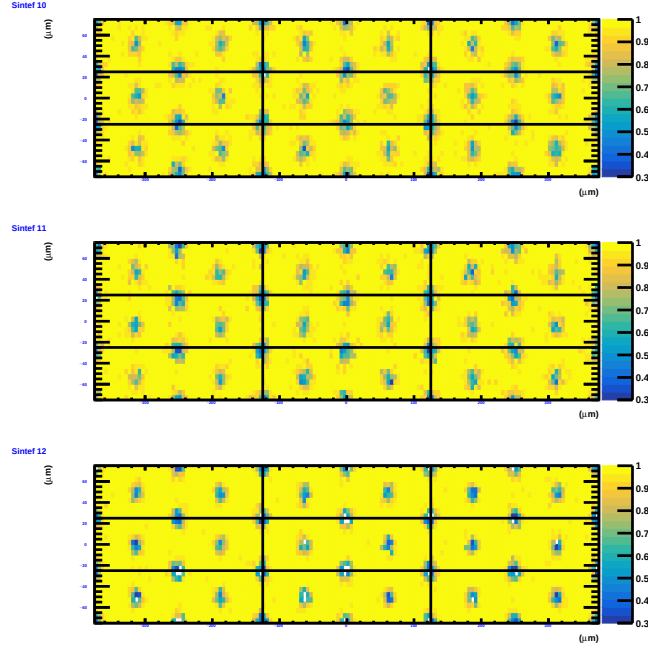


Figure 4. Efficiency maps averaged over the surface of a pixel area corresponding to 3×3 pixels, for the three sensors tested.

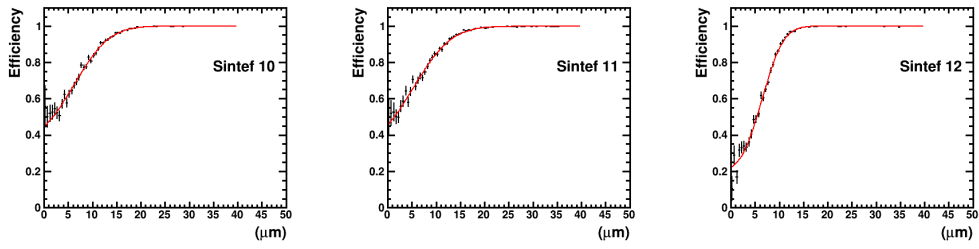


Figure 5. Measured efficiencies as function of predicted distance of a track impact from an electrode. The red lines correspond to the efficiency model described in the text.

4.3 Efficiency towards the edges

In order to evaluate the usefulness of the etched trench around the sensors, special runs were performed where the beam hit the sensor close to the edges. In fig. 6, plots of the efficiency profiles for the outermost pixels along the short and the long edges of the sensors are shown. The sensitive area along the short and long sides are extending about $100\ \mu\text{m}$ beyond the size of a standard pixel.

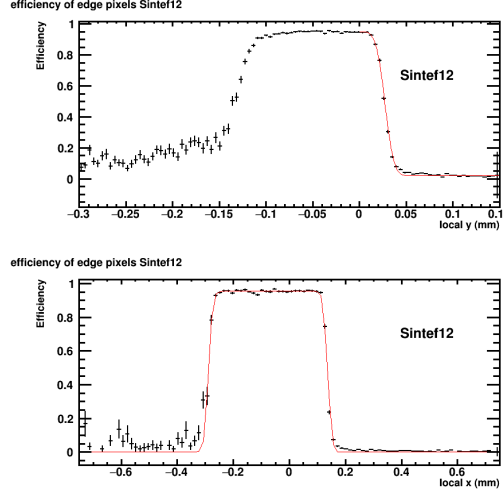


Figure 6. Efficiency profiles close to the sensor boundaries. The red lines show the result of fits to an edge (box) smeared with a gaussian. The upper plot shows the efficiency along the coordinate with $50\ \mu\text{m}$ pixel pitch. The fitted edge is at $y=27\ \mu\text{m}$. The $16\ \mu\text{m}$ trench is centered at $y = -0.1\text{mm}$. In the lower plot, the fitted width of the box is $425\ \mu\text{m}$, centered at $x=-76.5\ \mu\text{m}$, thus placing the left edge at $x=-289\ \mu\text{m}$. The trench is location is nominally at $x = -0.2\text{mm}$.

5 Conclusion and outlook

It is shown that 3D sensors produced at SINTEF are performing as expected with full efficiency at a bias voltages between 5 and 15V. Given the inherent radiation hardness of the design, these sensors might thus be considered as alternatives for use in harsh radiation conditions, such as in experiments at the High luminosity LHC. A number of radiation hardness studies of SINTEF 3D sensors from this batch are reported in [8] and show that properties after irradiation are as expected. Unfortunately, due to the very low number of modules available, complete results on module functionality after proton irradiation could not be extracted for this batch of sensors. Sensors from a new production at SINTEF have recently become available ("Run 4"). Preliminary wafer measurements show promising results on yield. Work is underway to perform complete tests of sensors from Run 4.

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